Optical patterning of magnetic domains and defects in ferromagnetic liquid crystal colloids

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A promising approach in designing composite materials in high and notice all phasical behalion combines, so olid nance, rich response it is and orien a ionall ordered of materials of materials and orien a ionall ordered of materials of materials of heir consistency of materials of can be high emergen behalior. So chas, ferromagne ic ordering of colloidal metal nanoparticles, forming mesos copic magne it a ion domain, hen dispersed in a nematic liquid cross al. Here, eldemons, rale he optical paterning of domains, rich response of magne iceles. Or noting, relation response of hedefocs, in his of materials of materials of materials. Or noting, relation response of hedefocs, in his of materials of materials of materials. Or noting relation on one-polar nematics, and ferromagnes, alike. © 2015 AIP P bis LLC. [high p://d.doi.org/10.1063/1.4928552]

Liq id cr., al (LC) colloid, a rac a con iderable amo n of, cien i c in era, dri en b he richna, of heir

ill mina ion, $95 \mu l$ of pen lc anobiphen 1 (5CB, Cheng hi Yongh a Di pla Ma erial Co. L d.) a mi ed i h 5μ l of a oben ene-con aining Beam 1205 LC (Beam Co.). Nonis omeri ing FLCG (pro ocol 2) ili ed for, rface-enabled op ical defec pa erning ere ba ed on ς ing 100 μ l of p re 5CB a, he ho, medi m, b he prepara ion pro ocol a, he s ame o her i e. Silane-PEG capped magne ic nanopla eles dis per ed in e hanol ere hen added o he LC hile follo ing he dispersion proced respectively reported pre io $_{\infty}1.5 \mu l$ of e hanol a added o $15 \mu l$ of he LC mi re o bring i o he is o ropic phase, follo ed b adding 15 μ l of 0.5 1 . % magne ic pla eles dispers ed in e hanol. Thes ample as kep a 90°C for 3h of ll e apora e he e hanol, ielding an e cellen di per ion in he i o ropic pha e a ero eld, and hen a rapidl cooled o he nema ic pha e of he mi hile igoro, 1, irring. The en ing FLCC a cen rif ged a 2000 rpm for 5 min o remo e regid al aggrega ion o ha he nal compo, i e con ained onl ell-di, per, ed pla eles. The nal frac ion of magne ic pla eles in he LC as a ried i hin 0.05 0.1 . %, a, de ermined ba, ed on ab, orbance and magne i a ion al &. Nanopla eles e hibi eds pon aneo alignmen i h large-area face, or hogonal o $\mathbf{n}(\mathbf{r})$ and magne ic momens along n(r), as con rmed b meas ring polari a ion-dependen ab, orbance 16 and probing re, pon, e of heir dil e di per ion o magne ic eld. Di per ion of ferromagne ic pla eles in he LC mi re eres able a all sed eld, (p o 20 mT) e hibi ing a facile re, pon, e alread a eld belo 1 mT. Homeo ropic glas cell i h pol domain FLCC, and M poin ing in one of he o an i-parallel direcion, along he erical far-eld director \mathbf{n}_0 ere prepared sing 1- or 0.17-mm hick glass place rea ed i h an aq eo₅ 5 ol ion of 0.1 .% N,N-dime h 1-N-oc adec 1-3-aminoprop 1- rime ho sil 1 chloride (DMOAP, Acros Organics) ia dip-coa ing. The cell gap hickness of $30 \,\mu m$ or $60 \,\mu m$ a, se b in ers pacing he glass place a heir edge, i h UV-c rable op ical adhe, i e (NOA-65, Norland Prod c_s) or con aining, ilica, pacer, of corre, ponding diame er, . Cell lling a done a room empera re sing capillar ac ion. FLCC cells e hibis pon aneos forma ion of random magne ic domain, of la eral dimen, ion, picall comparable or some ha larger han he cell hickness and dependen on he ini iali a ion eld of 10 35 mT (Ref. 4 and 16) (Fig. 1

he orien a ion of $\mathbf{M}(\mathbf{r})$ ip, o an oppos i e in-plane orien aion, a, depic ed in Fig. 3(b), al ho gh $\mathbf{n}(\mathbf{r})_{\mathcal{S}}$ as con in os (Fig. 3(a)) becas e half-in eger defecs are allo ed in he $\mathbf{n}(\mathbf{r})$ line eld b no in he $\mathbf{M}(\mathbf{r})$ ec or eld.

Al ho gh, in principle, im I aneo, pa erning of bo h $\mathbf{M}(\mathbf{r})$ and $\mathbf{n}(\mathbf{r})$ can be achie ed b combining he approache de cribed abo e, i i in ere ing o no e he e ol ion of domain s r c reg in M(r) hen onl he director is pa erned (Fig. 4). The $\mathbf{M}(\mathbf{r})$ i hin magne ic domain, in he pa erned region follo s_s he pa iall ar ing $\mathbf{n}(\mathbf{r})$ i hin he magne ic domain, and beha a di con in o.s l (ipping o oppo i e domain) a he in er-domain all . A applied magne ic eld, he pol domain na re of he FLCC in erplas ih he opologicall req ired all connec ing he halfin eger defec line, in $\mathbf{n}(\mathbf{r})$, ca, ing a comple pa ern of domain, and all defecs in ers pacing hem, hich lo 1 e ol e i h ime and, rongl depend on bo h he direc ion and reng h of B. In ere, ingl, he id h of all defecs i hin he region, of di or ed n(r) is of en larger han ha in region, of niform direc or (Fig. 4). To not er he na re of magne ic in er-domain all in he FLCC, e s ed dark eld micro cop ob er a ion, ha re eal bo h loca ion, and oriena ion, of indi id al nanopla eles & pplemen ar ideo S1)²² a ero eld and hen B a differen orien a ion, selec i el i che he domain, of opposi e M. Unlike in con en ional magne ic s s em, here magne ic domain, are

epara ed b he o-called Bloch or Néel all i h con in o_{-s_0} albei locali ed_{-s_0} oli onic deforma io_{-s_0} of M(r), magne i a ion a he in er-domain all, of he FLCC, i, no de ned, s_0 o ha he are s_0 ing lar in na re. This is becase s_0 e s_0 and n(r) are, rongl co pled, o ha he, oli onic deforma ion, of $\mathbf{M}(\mathbf{r})$ be een he domain, o ld be co, 1 in erm, of he corra ponding ela ic deforma ion of $\mathbf{n}(\mathbf{r})$. In ead, he domain all in he FLCC ha e niform direc or b $M(r)_{r}$ o ha here is no as ocia ed elas ic free energ cos d e o.s ch all. A applied eld, he in er-domain all can be par iall depri ed of nanopar icle, & pplemen ar ideo S1) and ranging in id h from he a erage-s pacing be een indi id al nanopar icla, o $\sim 1 \mu m$, a, de ermined b colloidal in erac ion, be een nanopla ele, i h differen l orien ed dipole momens of he neighboring domain, of oppo- \mathbf{x}_{i} i e $\mathbf{M} \| \mathbf{n}_{0}$. When $\mathbf{n}(\mathbf{r}) \| \mathbf{M}(\mathbf{r}) \|$ i hin he domain \mathbf{x}_{i} die or ed, his in erpla is f r her al ered b he energe ic co, of elas ic dis or ions (Fig. 4). Al ho gh he domain all defects in he FLCC₃ are $_{5}$ ing lar in M(r),12Li482769(TP)J(960)49/JF(31)T8,.48296(1)1327(1) and Y. Zhang. This rest earch as poor ed b he NSF gran DMR-1420736. A.J.H. and I.I.S. ackno ledge he AFSOR fac 1 fellous hip and he has pitali of he Air Force Rest earch Labora or diring he ime hen his ork as nder prepara ion for piblica ion.

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